

Supporting Information

“Like-Likes-Like” strategy for the design of electron transport materials and emitters with facilitated interlayer electron transport and improved efficiency

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1. The equation of Lippert-Mataga

$$v_f = \frac{2\mu_e(\mu_e - \mu_g)}{4\pi\epsilon_0 h c a^3} \Delta f + C \quad (1)$$

$$\Delta f = \frac{\epsilon - 1}{2\epsilon + 1} - \frac{0.5(n^2 - 1)}{2n^2 + 1} \quad (2)$$

$$a = \left(\frac{3M}{4N\pi d} \right)^{\frac{1}{3}} \quad (3)$$

where μ_g is the ground-state dipole moment, a is the solvent cavity (Onsager) radius, which was derived from Avogadro's number (N), molecular weight (M), and density ($d = 1$), and ϵ , ϵ_0 , and n are the solvent dielectric constant, vacuum permittivity, and solvent refractive index, respectively.

2. Electron-only device study

Electron-only devices were fabricated for the studies of electron mobility by using space charge limited current (SCLC) method. The device structure is ITO/Al (100 nm)/PTB7:PC₇₁BM (100 nm)/Ca (20 nm) /Al and ITO/ Al/PTB7:PC71BM (100 nm)/MSAPBS (x nm) /Al.

The SCLC is described by modified Mott-Gurney's law³:

$$J = (9/8)\epsilon_0\epsilon_r\mu(V^2/d^3)\exp[-0.89\beta(V/d)^{0.5}]$$

We can get the following formula:

$$\ln(Jd^3/V^2) \approx 0.89\beta(V/d)^{0.5} + \ln(9\epsilon_0\epsilon_r\mu/8)$$

The results are plotted as $\ln(Jd^3/V^2)$ versus $(V/d)^{0.5}$, as shown in Figure S8. J stands for current density, d is the thickness of the active layer, V is the applied potential, ϵ_r is the relative

dielectric constant of the blend (assuming that 3.5), ϵ_0 is the permittivity of free space ($8.85 \times 10^{-12} \text{ C V}^{-1} \text{ s}^{-1}$), β is the field activation factor and m the electron mobility.

3. hotophysical Equation

The rate constants were determined using the following basic photophysical functions

$$\phi_{PF} = \phi_{PL} R_{prompt} \quad (\text{S1})$$

$$\phi_{DF} = \phi_{PL} R_{delayed} \quad (\text{S2})$$

$$k_r^s = \phi_{PF} / \tau_{PF} \quad (\text{S3})$$

$$\phi_{PL} = k_r^s / (k_r^s + k_{nr}^s) \quad (\text{S4})$$

$$\phi_{PF} = k_r^s / (k_r^s + k_{nr}^s + k_{ISC}) \quad (\text{S5})$$

$$\phi_{ISC} = k_{ISC} / (k_r^s + k_{nr}^s + k_{ISC}) \quad (\text{S6})$$

$$\phi_{hRISC} = \phi_{DF} / \phi_{ISC} \quad (\text{S7})$$

$$k_{hISC} = \phi_{hRISC} (k_{hRISC} + k_{IC}^{Tn}) \quad (\text{S8})$$

$$k_{PF} = 1 / \tau_{PF} \quad (\text{S9})$$

$$k_{DF} = 1 / \tau_{DF} \quad (\text{S10})$$

here ϕ_{PL} is the photoluminescence quantum yield (PLQY). ϕ_{PF} and ϕ_{DF} are the prompt and delayed fluorescence efficiencies, respectively. ϕ_{ISC} and ϕ_{hRISC} are the ISC and h RISC efficiencies, respectively. τ_{PF} and τ_{DF} are the prompt and delayed fluorescent lifetimes, respectively. k_r^s , k_{nr}^s , k_{ISC} , k_{hRISC} , k_{IC}^{Tn} , k_{PF} and k_{DF} are the rates of singlet radiation, singlet non-radiation, ISC, h RISC, IC from T_n to $T1$, prompt fluorescence and decay fluorescence processes, respectively. R_{prompt} and $R_{delayed}$ are the component ratios of prompt and delayed fluorescence, respectively.

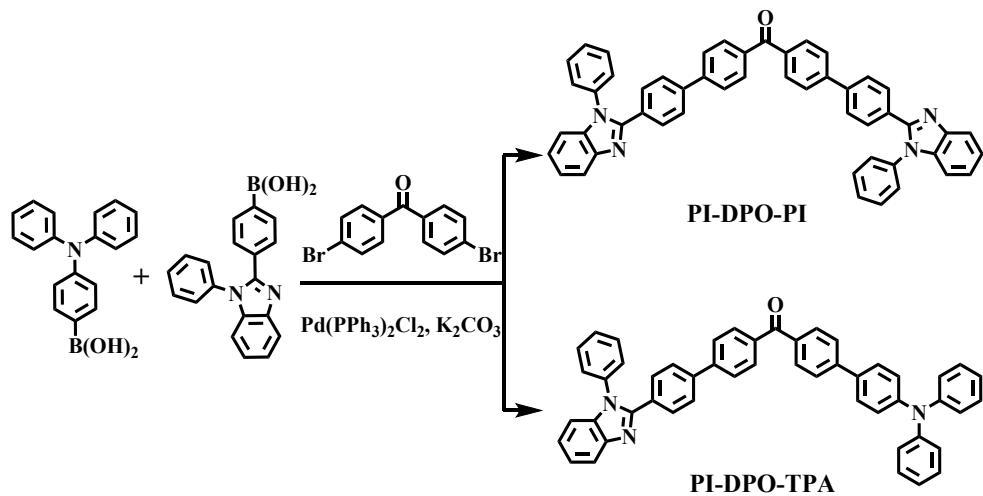


Figure S1 The synthetic route of PI-DPO-TPA and PI-DPO-PI

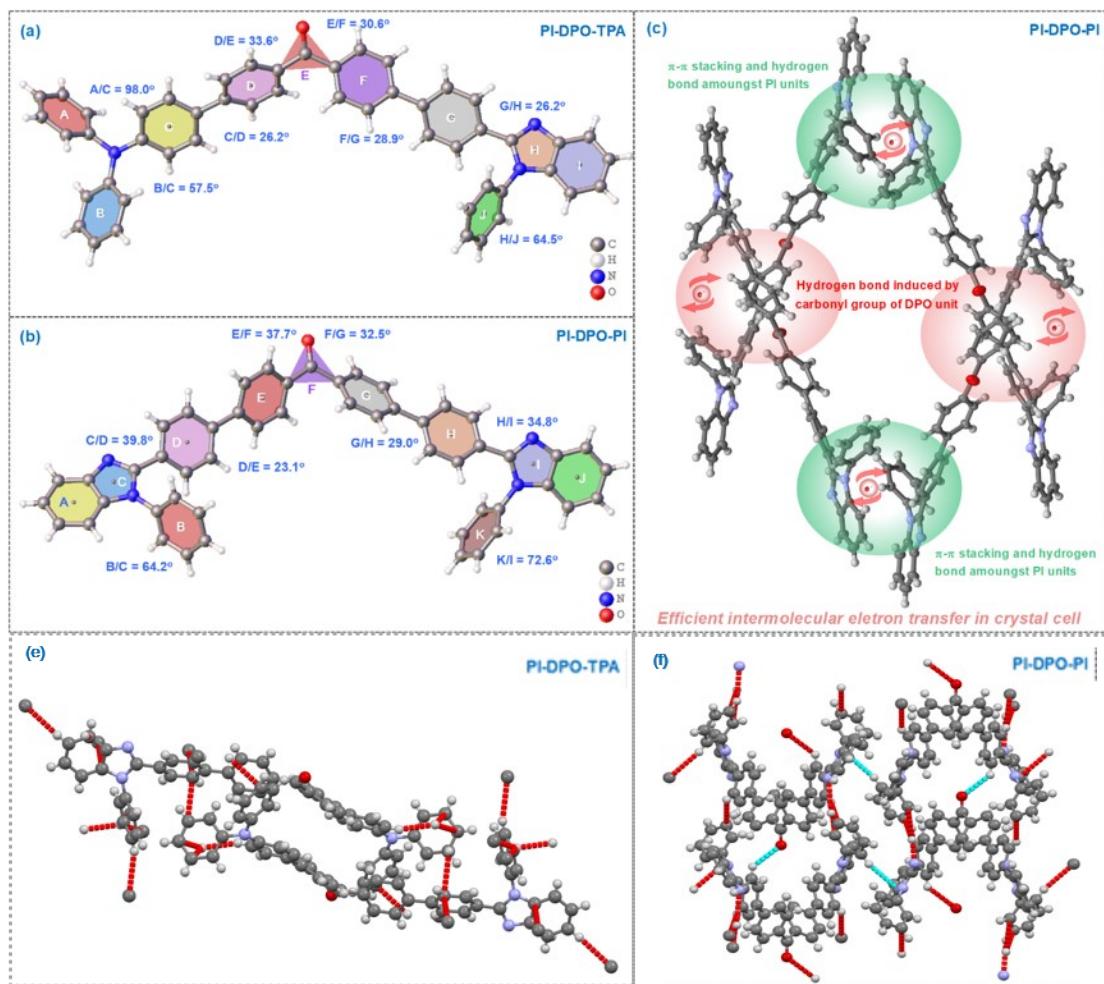


Figure S2 Torsion angle of (a) PI-DPO-TPA, (b) PI-DPO-PI in crystal cell, (c) the lattice conformation of PI-DPO-PI, (e) packing structure and multiple interactions of PI-DPO-TPA, and (f) packing structure and multiple interactions of PI-DPO-PI.

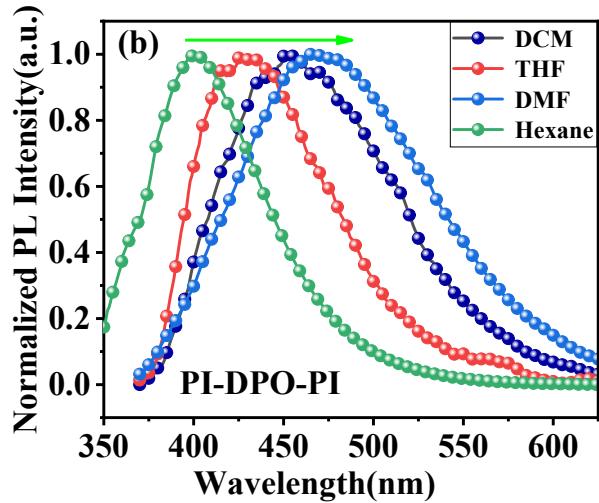


Figure S3 The emission of PI-DPO-PI in different solvents

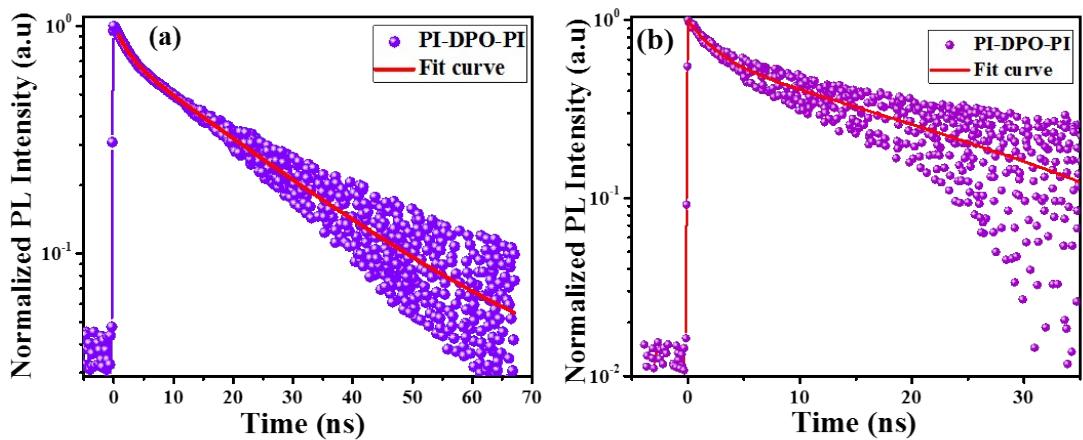


Figure S4 The fluorescent decay of PI-DPO-TPA and PI-DPO-PI in neat film

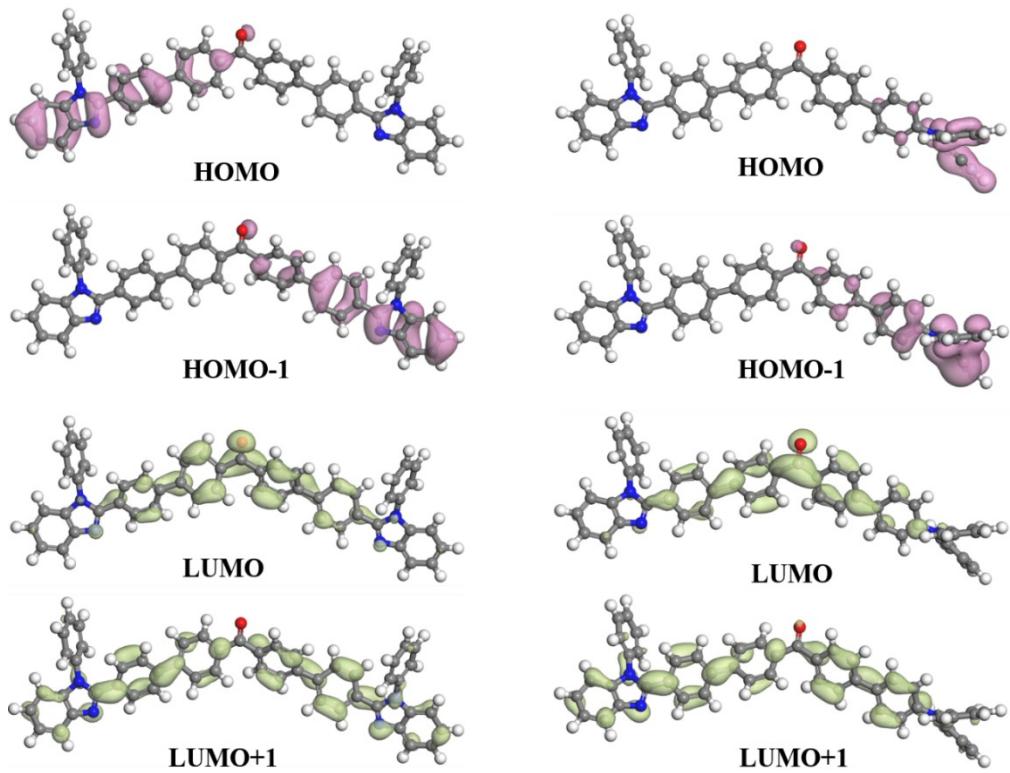


Figure S5 The densities of HOMOs and LUMOs of PI-DPO-TPA and PI-DPO-PI

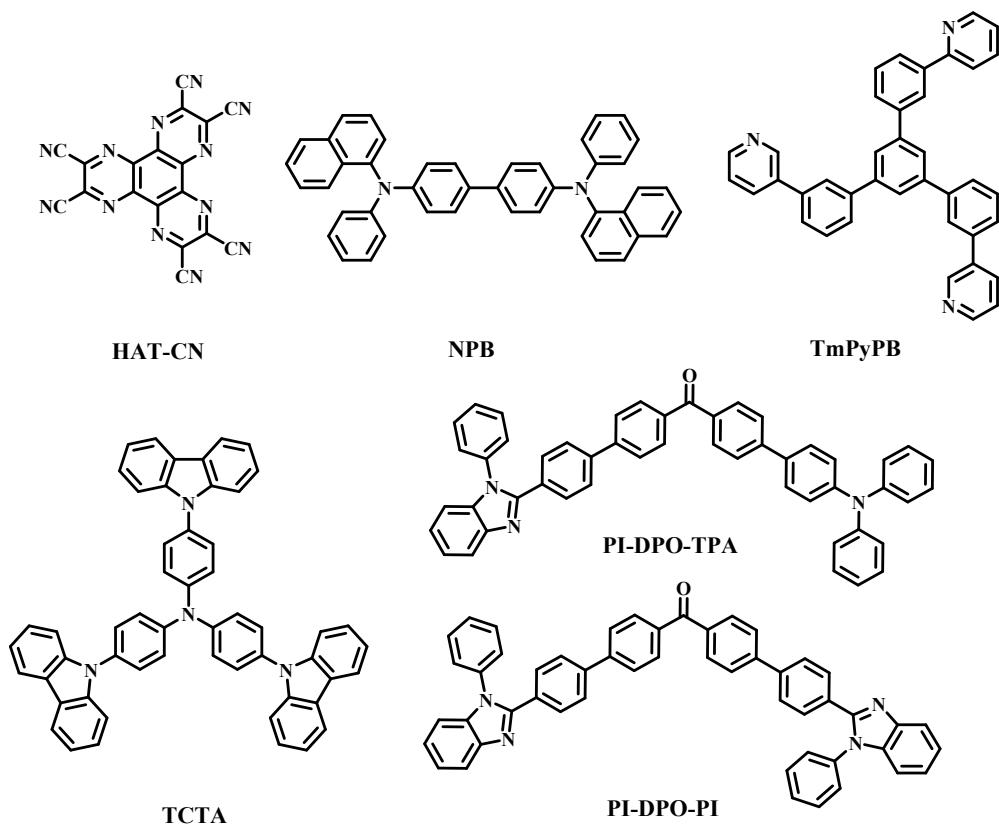


Figure S6 The chemical structures of the involved materials for the electroluminescent devices

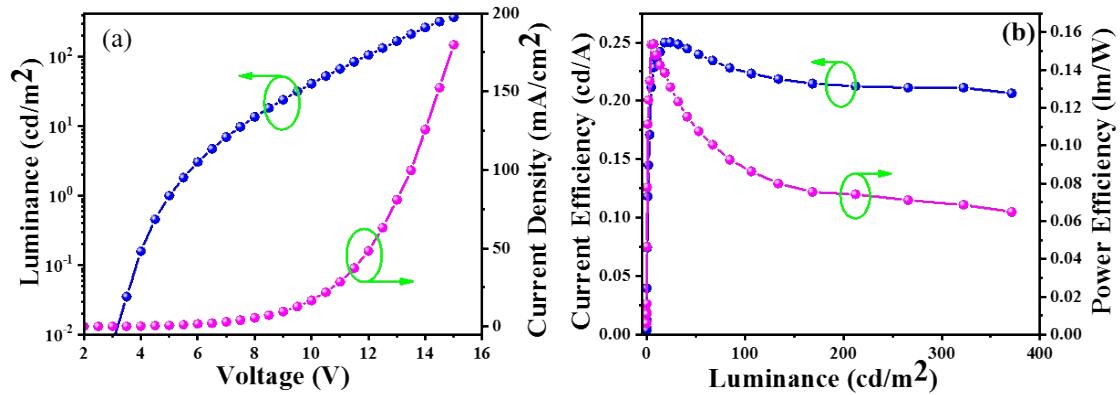


Figure S7 The device performance by using PI-DPO-PI as emitter and PI-DPO-TPA as EMT

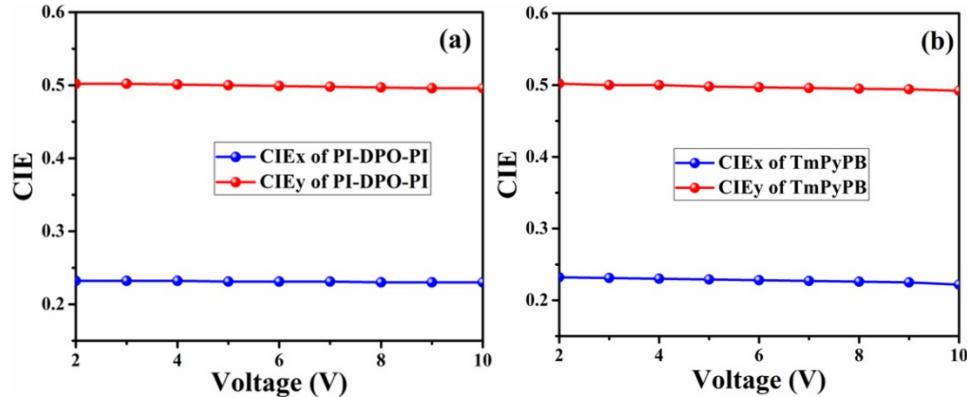


Figure S8 The CIE coordinates deviation of EL spectra in response to the voltage change of PI-DPO-PI and TmPyPB devices

Table S1. Crystal data and structure refinement for PI-DPO-TPA

Compound	PI-DPO-TPA
Empirical formula	C ₅₀ H ₃₅ N ₃ O
Formula weight	693.81
Temperature/K	296(2)
Crystal system	triclinic
Space group	P-1
a/Å	9.8097(19)
b/Å	9.863(2)
c/Å	19.713(4)
α/°	88.450
β/°	78.609
γ/°	80.356
Volume/Å ³	1843.3(6)
Z	2
ρ _{calc} g/cm ³	1.250
μ/mm ⁻¹	0.075
F(000)	728
Crystal size/mm ³	0.21 × 0.18 × 0.16
Radiation	Mo Kα ($\lambda = 0.71073$)
Index ranges	-12 ≤ h ≤ 8, -12 ≤ k ≤ 12, -24 ≤ l ≤ 25
Reflections collected	11630
Goodness-of-fit on F ²	0.965
Final R indexes [I>=2σ (I)]	R ₁ = 0.0609, wR ₂ = 0.1355
Final R indexes [all data]	R ₁ = 0.1393, wR ₂ = 0.1072
Largest diff. peak/hole / e Å ⁻³	0.001/0.0

Table S2. Crystal data and structure refinement for PI-DPO-PI

Compound	PI-DPO-PI
Empirical formula	C ₅₄ H ₃₄ N ₄ O
Formula weight	754.85
Temperature/K	296(2)
Crystal system	monoclinic
Space group	P21/n
a/Å	10.674(5)
b/Å	23.048(10)
c/Å	17.005(7)
α/°	90
β/°	91.185(5)
γ/°	90
Volume/Å ³	4182(3)
Z	4
ρ _{calc} g/cm ³	1.199
μ/mm ⁻¹	0.072
F(000)	1576
Crystal size/mm ³	0.19 × 0.17 × 0.15
Radiation	Mo Kα ($\lambda = 0.71073$)
Index ranges	-13 ≤ h ≤ 13, -29 ≤ k ≤ 18, -21 ≤ l ≤ 22
Reflections collected	9528
Goodness-of-fit on F ²	0.957
Final R indexes [I>=2σ (I)]	R ₁ = 0.0616, wR ₂ = 0.1457
Final R indexes [all data]	R ₁ = 0.1595, wR ₂ = 0.1862
Largest diff. peak/hole / e Å ⁻³	0.0/-0.0

Table S3. Photophysical property of the neat PI-DPO-TPA and PI-DPO-PI films

compounds	ϕ_{PL}	τ_{PF}	τ_{DF}	k_{PF}	k_{DF}	k_{ISC}	k_{hRISC}	k_r^s	k_{nr}^s	k_{IC}^{Tn}	ϕ_{ISC}	ϕ_{hRISC}	ϕ_{hRISC}/ϕ_{ISC}
	[%]	[ns]	[ns]	[10^8 s^{-1}]	[%]	[%]							
PI-DPO-TPA	60.6	2.19	22.1	4.57	0.45	2.83	1.18	1.05	0.68	1.89	61	61	1.0
PI-DPO-PI	5.2	2.26	26.81	4.42	0.37	2.50	0.83	0.11	2.02	1.05	54	54	1.0

Table S4. Comparison on device performance of different emitters with hot-exciton characterization

Light color	Emitters	V _{on} (V)	EQE (%)	PE (lm/w)	CE (cd/A)	Literatures
Green	PI-DPO-TPA	2.0	8.45	16.91	18.87	This work
	CzP-BZP	4.0	6.95	16.38	23.99	[1]
	CADPPI	2.8	4.78	10.84	9.85	[2]
	DPIAPPB	2.8	4.15	6.16	6.56	
	Emitter 1	4.1	7.0	14.5	23.1	[3]
	Emitter 2	4.2	8.1	15.6	24.9	
Blue	2EHO-TPA-CNPE	3.5	5.5	5.4	6.1	[4]
	MPPIS-Cz	5.2	1.48	1.30	1.52	[5]
	MPPIS-TPA	6.1	1.34	1.28	1.46	
	PABP	4.1	6.31	4.65	5.85	[6]
Red	PAIDO	3.7	8.82	7.27	7.64	
	TPPI-BZPCN	2.8	3.33	4.28	7.60	[7]

Table S5. Comparison on device performance of ITO/HAT-CN/NPB/TCTA/emitters/ETMs/LiF/Al with different ETMs

Emitter/ETMs	V _{on} (V)	EQE (%)	PE (lm/w)	CE (cd/A)	Literatures
PI-DPO-TPA/PI-DPO-PI	2.0	8.45	16.91	18.87	This work
PI-DPO-TPA/TmPyPB	4.5	4.20	4.02	12.32	This work
TPA-SO ₂ /TPBi	2.7	3.91	5.46	5.26	[8]
DPAC-TAn-BI/TmPyPB	3.0	5.81	6.78	6.48	[9]
TPB-PAPC/TmPyPB	2.5	6.00	4.20	4.10	[10]
PAC/TPBi	4.4	10.03	6.94	12.37	[11]
CDE1/B3PYMPM	4.3	5.20	5.00	15.00	[12]
SBDBQ-PXZ/Bephen	2.4	5.60	10.50	12.00	[13]
o-ACSO ₂ /TmPyPB	5.2	5.90	7.80	14.10	[14]
DCPDAPM/TmPyPB	6.1	1.34	1.28	1.46	[15]

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